### 原位水解沉积制备高效氮化钽微球太阳能分解水光阳极

杨立恒1 罗文俊\*,2,3 李明雪4 邹志刚\*,3

(1南京大学现代工程与应用科学学院,南京 210093)

(2江苏省柔性电子重点实验室,先进材料研究院,江苏先进生物与化学制造协同创新中心,

南京工业大学,南京 211816)

(3南京大学环境材料与再生能源研究中心,固体微结构国家重点实验室,南京大学物理学院,南京 210093) (4中国矿业大学物理学院,徐州 221116)

摘要:利用一种新的原位水解沉积方法,以在高湿度空气中老化的甲醇中作为溶剂,通过乙醇钽水解而成前驱体微球颗粒沉积,制备出了高效的  $Ta_3N_5$  微球光电极,其 1.6  $V(vs\ RHE)$ 电极电位下的光电流值达到了 6.6  $mA\cdot cm^{-2}$ 。相反地,在新鲜的甲醇溶液中没有钽前驱体微球颗粒沉积。这表明甲醇中水的含量对  $Ta_3N_5$  微球光电极的形成十分重要。另外,本制备方法也能方便地在其他透明导电衬底上制备出  $Ta_3N_5$ 。

关键词:太阳能水分解; Ta<sub>3</sub>N<sub>5</sub>光阳极; 微球; 原位沉积; 湿度

中图分类号: 0614.51+3 文献标识码: A 文章编号: 1001-4861(2016)10-1839-08

DOI: 10.11862/CJIC.2016.330

# In Situ Hydrolysis Deposition of an Efficient Ta<sub>3</sub>N<sub>5</sub>Microsphere Photoanode for Solar Water Splitting

YANG Li-Heng<sup>1</sup> LUO Wen-Jun<sup>\*,2,3</sup> LI Ming-Xue<sup>4</sup> ZOU Zhi-Gang<sup>\*,3</sup>

(<sup>1</sup>College of Engineering and Applied Science, Nanjing University, Nanjing 210093, China)

(<sup>2</sup>Key Laboratory of Flexible Electronics & Institute of Advanced Materials, Jiangsu National Synergetic Innovation Center for Advanced Materials, Nanjing Tech University, Nanjing 211816, China)

(<sup>3</sup>Eco-materials and Renewable Energy Research Center (ERERC), National Laboratory of Solid State (Microstructures, Colledge of Physics, Nanjing University, Nanjing 210093, China)

(4Department of Physics, China University of Mining and Technology, Xuzhou, Jiangsu 221116, China)

**Abstract**: A new *in situ* hydrolysis deposition method was used to prepare a Ta<sub>3</sub>N<sub>5</sub> microsphere photoanode, which indicates a high photocurrent of 6.6 mA·cm<sup>-2</sup> at 1.6 V vs RHE. Microsphere precursor films are formed by hydrolysis of Ta(OEt)<sub>5</sub> and subsequent deposition on substrates, which is achieved by aging methanol solvent in air with high humidity. In contrast, no precursor films were obtained on substrates with fresh methanol. The results suggest that water in solvent is very essential to *in situ* depositing Ta<sub>3</sub>N<sub>5</sub> photoanode. In addition, the facile method can be used to deposit Ta<sub>3</sub>N<sub>5</sub> on other transparent conducting substrates.

Keywords: solar water splitting; Ta<sub>3</sub>N<sub>5</sub> photoanodes; microsphere; in situ deposition; humidity

收稿日期:2016-04-26。收修改稿日期:2016-08-18。

国家重点基础研究发展计划(973 计划, No.2013CB632404, 2014CB239303)、江苏省自然科学基金(No.15KJB150010, BK20140197)、南京大学纳米技术江苏省重点实验室开放研究基金资助项目。

<sup>\*</sup>通信联系人。E-mail:iamwjluo@njtech.edu.cn,zgzou@nju.edu.cn

### 0 Introduction

Since a TiO<sub>2</sub>-bas ed photoelectrochemical (PEC) cell was reported to split water into H2 and O2 under illumination, solar water splitting has been considered to be a promising technology to produce H<sub>2</sub> on a large scale<sup>[1]</sup>. Ta<sub>3</sub>N<sub>5</sub> is regarded as one of the most promising candidates due to its high theoretical energy conversion efficiency (15.9%) and suitable band positions [2-3]. Many preparation methods, such as thermal oxidation and nitridation of Ta foil, throughmask anodization anodization, combined hydrothermal method, electrophoretic deposition, dropcasting and magnetron sputtering, have been reported to prepare Ta<sub>3</sub>N<sub>5</sub> [49]. However, p-n tandem photoelectrochemical cell requires efficient and translucent/ transparent Ta<sub>3</sub>N<sub>5</sub> photoanode, which still remains unfulfilled. Therefore, it is still desirable to explore new preparation methods of Ta<sub>3</sub>N<sub>5</sub> films. In addition, spherical structure can lead to efficient light absorption and improve performance of a photoelectrode [10-11]. However, current preparation methods for spheres are often in the assistance of additional reagents, which increases preparation cost<sup>[12-13]</sup>.

Herein. an efficient microsphere Ta<sub>3</sub>N<sub>5</sub> photoanode was prepared by a new in situ hydrolysis deposition method without any additional reagents. Microsphere precursor films were firstly deposited on substrates in tantalum ethoxide (Ta(OEt)<sub>5</sub>) solution of aged methanol. After oxidation and nitridation, microsphere Ta<sub>3</sub>N<sub>5</sub> films were obtained. A 6.6 mA. cm<sup>-2</sup> photocurrent was achieved at 1.6 V vs RHE. In this context, exploration of new preparation method and the synthesis mechanism of Ta<sub>3</sub>N<sub>5</sub> film are our research focus and we hope it can give some hints for preparation of efficient and translucent/transparent  $Ta_3N_5$ .

#### 1 Experimental

## 1.1 Preparation of Ta<sub>3</sub>N<sub>5</sub> microsphere photoanodes

A typical preparation procedure of  $Ta_3N_5$  microsphere photoanode is as follows. Firstly,

methanol (Purity≥99.5%, Nanjing Chemical Reagent Co., Ltd.) was aged in air with 7% relative humidity at 25 °C for 4 h before use. Secondly, 10 mmol·L<sup>-1</sup> precursor solution of tantalum ethoxide (Purity ≥ 99.95%, Zhuzhou Cemented Carbide Group Corp., Ltd) was prepared with aged methanol. Then, Ta foils (Purity ≥99.95%, Zhongnuo Advanced Material Technology Co., Ltd) were immersed in Ta (OEt)<sub>5</sub> methanol solution and films were deposited at 7 °C for 48 h. Next, the obtained films were rinsed with deionized water and dried in air at room temperature, followed by calcination in air at 250 °C for 30 minutes. Finally, Ta<sub>3</sub>N<sub>5</sub> microsphere photoanodes were obtained by nitridation of oxidized samples in a horizontal tube furnace at 850 °C for 500 min under 800 mL·min<sup>-1</sup> NH<sub>3</sub> flow (Referred as Ta<sub>3</sub>N<sub>3</sub>/aged and Ta<sub>3</sub>N<sub>3</sub>/aged/Copristine and Co-Pi loaded respectively). In order to investigate the effect of aging methanol, a reference sample was prepared in fresh methanol as solvent under the same conditions (Referred as Ta<sub>3</sub>N<sub>5</sub>/fresh and Ta<sub>3</sub>N<sub>5</sub>/fresh/Co-Pi for pristine and Co-Pi loaded samples, respectively).

## 1.2 Photo-assisted electrodeposition of Co-Pi co-catalyst

Following previous studies, Co-Pi co-catalyst was electrodeposited on Ta<sub>3</sub>N<sub>5</sub> film by chronopotentiometry under illumination with constant current of 50 µA for 4 min [5]. The electrodeposition was conducted in a three-electrode cell, with the solution of 0.5 mmol·L<sup>-1</sup>  $Co(NO_3)_2 \cdot 6H_2O$  (Purity  $\geq 99.0\%$ , Shanghai Zhenxin Reagent Factory) and 0.1 mol·L<sup>-1</sup> K<sub>2</sub>HPO<sub>4</sub>·3H<sub>2</sub>O (Purity≥99.0%, Shanghai Lingfeng Chemical Reagent Co., Ltd.) buffer at pH=7 as electrolyte. Ta<sub>3</sub>N<sub>5</sub> was used as working electrode, Pt foil as counter electrode and saturated calomel electrode (SCE) as reference electrode. An AM 1.5G-simulated sunlight simulator (Oriel 92251A-1000, light intensity = 100 mW  $\cdot$  cm<sup>-2</sup>) was used as light source. During the deposition process, Co<sup>2+</sup> was oxidized into Co<sup>3+ [14-15]</sup>. The total amount of charge was about 20 mC·cm<sup>-2</sup>. Assuming that Faradaic efficiency was 100%, the amount of deposited Co was calculated as follow:

$$N_{co} = 20 \times 10^{-3}/96 \ 485 = 0.2 \ (\mu \text{mol} \cdot \text{cm}^{-2})$$
 (1)

Where  $N_{\text{Co}}$  is the amount of Co-Pi deposited on  $\text{Ta}_3\text{N}_5$  per square centimeter. 96 485 (C·mol <sup>-1</sup>) is the Faradaic constant.

After Co-Pi deposition, the electrode was rinsed with deionized water and dried in air for use.

#### 1.3 Characterization of samples

crystal structures of samples were determined by an X-ray diffractometer (XRD, Rigaku Ultima III) with Cu  $K\alpha$  ray ( $\lambda$ =0.154 3 nm) at 40 kV and 40 mA. The range is from  $10^{\circ}$  to  $80^{\circ}$ . Morphologies of electrodes were observed on a field emission scanning electron microscope (SEM, Zeiss, Ultra 55-44-08) at an accelerating voltage of 15 kV. Water content of methanol was measured on a moisture analyzer (Metrohm, KF787 Titrino). Absorption spectra were investigated on a UV-vis spectrophotometer (Shimadzu, UV-2550). FTIR spectra were obtained on a Nexus870 spectrophotometer in the range of 4 000 ~400 cm<sup>-1</sup>. Thermogravimetric analysis was carried out in air with a Netzsch STA 449F3 instrument by increasing temperature from 30 to 600 °C with 5 °C ⋅ min<sup>-1</sup>.

#### 1.4 Photoelectrochemical measurements

Photoelectrochemical performance was measured in a three-electrode cell using an electrochemical analyzer (CHI-633C, Shanghai Chenhua).  $Ta_3N_5$  microsphere electrode was used as working electrode, Pt foil as counter electrode and saturated calomel electrode (SCE) as reference electrode. Aqueous solution of 1 mol  $\cdot$ L  $^{-1}$  NaOH was employed as electrolyte. A commercial AM 1.5G-simulated sunlight simulator (Oriel 92251A-1000, light intensity =100 mW  $\cdot$ cm $^{-2}$ ) was used as light source. Current-potential curves were recorded at a scan rate of 10 mV  $\cdot$ s $^{-1}$ . The

potential of working electrode versus SCE was converted into RHE (reversible hydrogen electrode) potential scale according to the following formula:

$$V_{\rm RHE} = V_{\rm SCE} + 0.242 + 0.059 {\rm pH}$$
 (2) where  $V_{\rm RHE}$  is the potential versus RHE(V),  $V_{\rm SCE}$  is the potential versus SCE (V), and pH is the pH value of electrolyte. The incident photon-to-current efficiency (IPCE) was determined under the irradiation of different wavelength light generated by monochromatic filters according to the following formula:

IPCE = 1 240 
$$I_{\rm ph}$$
 / ( $P\lambda$ ) (3) where  $I_{\rm ph}$  is the photocurrent density ( $\mu$ A·cm<sup>-2</sup>),  $P$  and  $\lambda$  are the incident light intensity ( $\mu$ W·cm<sup>-2</sup>) and wavelength (nm), respectively. The incident light intensity was measured by a photometer (Newport, 84 0-C, USA).

#### 2 Results and discussion

Fig.1 shows photographs of Ta(OEt)<sub>5</sub> solution of fresh and aged methanol before and after deposition, respectively. Both solutions are transparent at the beginning. After depositing at 7 °C for 48 h, solution of aged methanol became white (Fig. 1(b)). However, solution of fresh methanol was still transparent. White films were deposited on substrates in solution of aged methanol, whereas there were no samples on substrates in solution of fresh methanol. The results suggest that film deposition comes from hydrolysis of Ta(OEt)<sub>5</sub> in aged methanol. Since the only difference between the two kinds of methanol was the methanol whether exposed in moist air or not, little water in methanol was essential for the formation of films. The water content was measured about 0.15% (w/w) by a moisture analyzer. The detail effect of water will be



Fig.1 Photographs of precursor solution of (a) fresh and (b) aged methanol before and after deposition

discussed below.

XRD patterns were measured to determine phases and crystal structures of the two samples, as shown in Fig.2. Orthorhombic phase Ta<sub>3</sub>N<sub>5</sub> (PDF No. 19-1291) was obtained for Ta<sub>3</sub>N<sub>5</sub>/aged. In contrast, Ta<sub>3</sub>N<sub>5</sub>/fresh shows no peaks of Ta<sub>3</sub>N<sub>5</sub>. Fig.3 shows scanning electron microscopy (SEM) images of Ta<sub>3</sub>N<sub>5</sub>/fresh and Ta<sub>3</sub>N<sub>5</sub>/aged. Surface and cross-sectional SEM images in Fig.3 (a, c) indicate that Ta<sub>3</sub>N<sub>5</sub>/fresh shows only morphology of Ta substrate and no Ta<sub>3</sub>N<sub>5</sub> is observed. The result is in agreement with the XRD data. However, Fig.3 (b) shows that Ta<sub>3</sub>N<sub>5</sub>/aged is composed of spherical particles, with the diameter around 1μm. Discernible roughness, many nanopores and cracks are observed on the surface, which come from volume shrinkage from transition of Ta<sub>2</sub>O<sub>5</sub> into

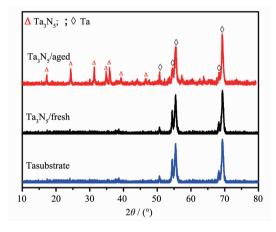
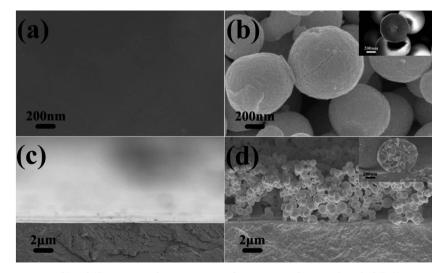


Fig.2 XRD patterns of Ta<sub>3</sub>N<sub>5</sub>/fresh and Ta<sub>3</sub>N<sub>5</sub>/aged

Ta<sub>3</sub>N<sub>5</sub> and the decomposition of residual organics (Fig.4) during nitridation  $^{[12]}$ . High magnification SEM image of precursor is displayed in the inset picture of Fig.3 (b). The result suggests that microspheres are formed during precipitation. Fig.3 (d) is the cross-sectional image of Ta<sub>3</sub>N<sub>5</sub>/aged. It shows that Ta<sub>3</sub>N<sub>5</sub> film electrode is composed of microsphere particles and the thickness is about 7.5 μm. From the inset in Fig.3 (d), Ta<sub>3</sub>N<sub>5</sub> microsphere is solid and composed of smaller particles, which suggests that Ta<sub>3</sub>N<sub>5</sub> microsphere originates from the agglomeration of nanoparticles.

Spherical is one of favorable structure microstructures in both photoelectrochemical and solar cells<sup>[10-11]</sup>. Usually, spherical Ta<sub>3</sub>N<sub>5</sub> particles obtained by solution methods are assisted with additional agents  $^{[12\text{-}13]}$ . Though the distribution size of  $Ta_3N_5$ spheres can be narrowed, introduction of additional reagents actually increases the possibility of inclusion of impurities, as well as experimental difficulties and preparation cost. In our study, however, Ta<sub>3</sub>N<sub>5</sub> microsphere was prepared in a more simple way, without any additional agents, and thus those shortcomings are avoided.

FTIR spectra were used to investigate formation process of microsphere, and the results are shown in Fig.4. Peaks below 1 000 cm<sup>-1</sup> are attributed to stretching, bending and torsion modes of Ta-O [16-17].



Inset images in (b) and (d) are microsphere precursor and cross-sectional image of cracked  $\text{Ta}_3\text{N}_5$ , respectively

Fig.3 High magnification SEM images of Ta<sub>3</sub>N<sub>3</sub>/fresh(a) and Ta<sub>3</sub>N<sub>3</sub>/aged(b); Cross-sectional images of Ta<sub>3</sub>N<sub>3</sub>/fresh(d) and Ta<sub>3</sub>N<sub>3</sub>/aged(d)

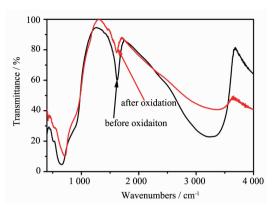


Fig.4 FTIR spectra of microsphere precursor before and after calcined at 250 °C for 30 min in air

The broad absorption between 800 and 1 000 cm<sup>-1</sup> corresponds to the presence of Ta suboxides<sup>[18]</sup>. A peak at ~3 342 cm<sup>-1</sup> is assigned to OH stretching modes, and peak at ~1 626 cm<sup>-1</sup> is associated with OH bending modes<sup>[17,19]</sup>. Both of them are weakened after calcination at 250 °C. The existence of -OH group confirms that microsphere is from the hydrolysis of tantalum ethoxide.

In order to further investigate composition of as-deposited microsphere precursor before calcination, thermogravimetric (TG) is measured and the result is shown in Fig.5. The endothermic peak under 100 °C comes from evaporation of adsorbed water. Weight loss with exothermic peak ended at around 500 °C arises from the decomposition of organics in microsphere, which comes from the organic group -CH<sub>2</sub>CH<sub>3</sub> of Ta (OEt)<sub>5</sub> <sup>[16-17]</sup>. However, organic compounds cannot be removed completely when calcined at 250 °C and thus lead to the formation of Ta suboxides.

According to the above discussion, formation process of  $Ta_3N_5$  microsphere can be concluded as follows with the simplified chemical reactions<sup>[20-21]</sup>:

Hydrolysis:

$$Ta(OR)_5 + H_2O \rightarrow$$

 $Ta(OR)_4(OH)+ROH(R=-CH_2CH_3)$ 

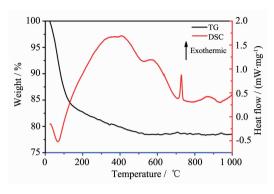


Fig.5 Thermogravimetric spectrum of microsphere precursor

Polycondensation:

$$(RO)_4$$
-Ta-O-H + Ta $(OR)_5$   $\rightarrow$   $(RO)_4$ -Ta-O-Ta- $(OR)_4$ +ROH  $(R=-CH_2CH_3)$ 

Water content in methanol is a key factor to trigger the whole reaction. Actually, the two reactions proceed simultaneously once the hydrolysiscondensation reaction is triggered. As long as a critical radius is reached, nucleation will take place. And nanocrystalline will agglomerate into spherical particle due to its lowest surface energy. Finally, when the spherical particles are big enough, sedimentation happens and a film is deposited on the substrate. After oxidation and nitridation, Ta<sub>3</sub>N<sub>5</sub> microsphere film is obtained. A schematic diagram of formation process of Ta<sub>3</sub>N<sub>5</sub> microsphere is illustrated in Fig.6.

Fig.7 indicates UV-Vis absorption spectrum of  $Ta_3N_5$  microsphere photoanode. The  $Ta_3N_5$  microsphere film shows a high absorption, which comes from light scattering of microspheres. Contribution from substrate is excluded through the absorption spectrum of  $Ta_3N_5$ / fresh. Ambiguous ERERC can be identified through the  $Ta_3N_5$  microsphere film on quartz substrate in the inset(II) of Fig.7, which suggests that *in situ* hydrolysis deposition method can be used to prepare a translucent  $Ta_3N_5$  microsphere electrode.

Photoelectrochemical properties of Ta<sub>3</sub>N<sub>5</sub> micro-

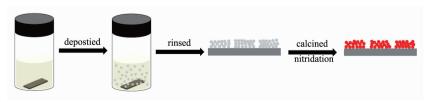
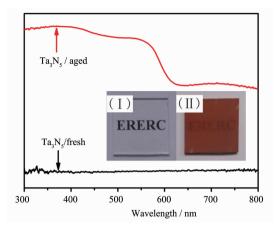


Fig.6 Schematic illustration of formation process of  $Ta_3N_5$  microsphere film



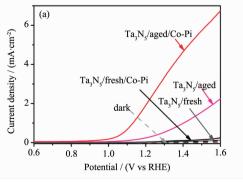
Inset pictures are photographs through (I) quartz substrate and (II) Ta<sub>3</sub>N<sub>2</sub>/aged on the quartz substrate, respectively

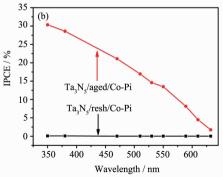
Fig.7 Absorption spectra of  $Ta_3N_5/fresh$  and  $Ta_3N_5/aged$  on the quartz substrate

sphere photonodes were measured and the results are shown in Fig.8. In order to exclude contribution of Ta substrate on photocurrent, Ta<sub>3</sub>N<sub>5</sub>/fresh was also measured as a reference. Dark currents of both electrodes are negligible. The photocurrent of Ta<sub>3</sub>N<sub>5</sub>/ fresh and Ta<sub>3</sub>N<sub>5</sub>/fresh/Co-Pi is much lower than that of Ta<sub>3</sub>N<sub>5</sub> microsphere photonode. Therefore, photocurrents of Ta<sub>2</sub>N<sub>5</sub>/aged and Ta<sub>2</sub>N<sub>5</sub>/aged/Co-Pi entirely come from Ta<sub>3</sub>N<sub>5</sub> microsphere, rather than from substrate. Generally, a bare Ta<sub>3</sub>N<sub>5</sub> photoanode suffers from severe photo-corrosion in aqueous solution and surface combination, which can be remarkably suspressed by depositing a co-catalyst. Among different co-catalysts, Co-Pi is low-cost and operable under mild conditions [14,22]. Therefore, in this

study, Co-Pi (2 µmol·cm<sup>-2</sup>) was electrodeposited on the Ta<sub>3</sub>N<sub>5</sub> film to improve the performance of the Ta<sub>3</sub>N<sub>5</sub> microsphere electrode. After deposition of Co-Pi, the photocurrent of Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi is about 3 times as high as that of Ta<sub>3</sub>N<sub>2</sub>/aged. Current density of Ta<sub>3</sub>N<sub>5</sub> microsphere electrode by in situ hydrolysis deposition method is ~2.34 mA·cm<sup>-2</sup> at 1.23 V vs RHE, and ~6.6 mA·cm<sup>-2</sup> at 1.6 V vs RHE. A Ta<sub>3</sub>N<sub>5</sub> photoanode prepared by EPD indicated 3.18 mA ·cm <sup>-2</sup> photocurrent at 1.23 V vs RHE and about 6 mA·cm<sup>-2</sup> at 1.6 V vs RHE<sup>[23]</sup>. High photocurrents of 5.5 mA· cm<sup>-2</sup> and 6.7 mA·cm<sup>-2</sup> at 1.23 V vs RHE have been achieved by direct oxidation and nitridation of Ta foil<sup>[4-5]</sup>. The photocurrent in this study is comparable to samples by EPD and oxidation and nitridation of Ta foil, but much lower than 12.1 mA·cm<sup>-2</sup> obtained by Ta<sub>3</sub>N<sub>5</sub> with integration of hole-storage layer, coupled molecular catalysts and TiO<sub>x</sub> blocking layer [6]. However, in this study, preparation conditions and cocatalysts have not yet been optimized. And thus it is promising to further improve Ta<sub>3</sub>N<sub>5</sub> microsphere photoanode by in situ hydrolysis deposition method in future work.

Fig.8 (b) is the incident photon-to-current efficiency (IPCE) of Ta<sub>3</sub>N<sub>5</sub>/fresh/Co-Pi and Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi. The IPCE of Ta<sub>3</sub>N<sub>5</sub>/fresh/Co-Pi is nearly zero in the spectrum range from 350 to 610 nm, which further excludes contribution of substrate on photocurrent. The IPCE of Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi is ~26% at 400 nm, but decreases at longer wavelength [24]. The integrated





Scan rate: 10 mV·s<sup>-1</sup>, Electrolyte: 1 mol·L<sup>-1</sup> NaOH (pH=13.6)

Fig.8 (a) Current-potential curves of Ta<sub>3</sub>N<sub>5</sub>/fresh, Ta<sub>3</sub>N<sub>5</sub>/fresh/Co-Pi, Ta<sub>3</sub>N<sub>5</sub>/aged and Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi in the dark (dash lines) and under AM 1.5G simulated sunlight irradiation (100 mW⋅cm<sup>-2</sup>) (solid lines), respectively; (b) IPCE curves of Ta<sub>3</sub>N<sub>5</sub>/fresh/Co-Pi and Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi at 1.23 V vs RHE

photocurrent (~2.35 mA·cm<sup>-2</sup>) shown in Fig.9 is very close to the measured value (~2.34 mA·cm<sup>-2</sup>), which suggests that the measured photocurrent is reliable. The photocurrent response of Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi in IPCE also agrees well with the absorption edge, suggesting that the photocurrent originates from the band gap transition of Ta<sub>3</sub>N<sub>5</sub>. The stability of Ta<sub>3</sub>N<sub>5</sub>/ aged and Ta<sub>3</sub>N<sub>2</sub>/aged/Co-Pi was also measured and the result is shown in Fig.10. As we can see, the photocurrent of Ta<sub>3</sub>N<sub>5</sub>/aged declines over 50% after only 3 ~4 s under illumination, but the time was extended to about 2 000 s for Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi. Though photocurrent of Ta<sub>3</sub>N<sub>5</sub>/aged/Co-Pi decreases obviously, nonzero photocurrent can still be observed. The stability of Ta<sub>3</sub>N<sub>5</sub> microsphere electrode should be further improved in future.

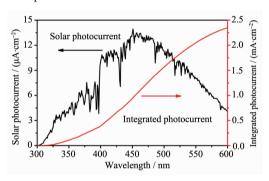
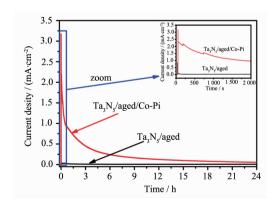


Fig.9 Integrated solar photocurrent at 1.23 V vs RHE from the standard solar spectrum



Electrolyte: 1mol·L<sup>-1</sup> NaOH (pH=13.6)

Fig.10 Current-time curves of Ta<sub>3</sub>N<sub>3</sub>/aged and Ta<sub>3</sub>N<sub>3</sub>/ aged/Co-Pi measured at 1.23 V vs RHE

#### 3 Conclusions

In summary, we synthesized an efficient  $Ta_3N_5$  microsphere photoanode by a new and facile in situ

hydrolysis deposition method. A Ta<sub>3</sub>N<sub>5</sub> microsphere film was formed on Ta substrate in Ta(OEt)5 solution of aged methanol. The microsphere is formed by hydrolysis of Ta(OEt)<sub>5</sub> and subsequent agglomeration of Water nanoparticles. content in solvent indispensable to in situ deposition of Ta<sub>3</sub>N<sub>5</sub> film. High photocurrent density was obtained on the Ta<sub>3</sub>N<sub>5</sub> microsphere electrode, ~2.34 mA·cm<sup>-2</sup> at 1.23 V vs RHE and ~6.6 mA·cm<sup>-2</sup> at 1.6 V vs RHE under AM 1.5G simulated sunlight irradiation (100 mW·cm<sup>-2</sup>). In addition, in situ hydrolysis deposition method is a method to prepare promising efficient photoanodes on other transparent conducting substr ates.

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